EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	64	("20020008954"|"20020101956"|"200 20109954"|"20020145714"|"20030155 080"|"20040012767"|"4522489"|"4969 168"|"5315473"|"5413360"|"5436790" |"5530616"|"5583786"|"5610683"|"58 38529"|"5880922"|"6055150"|"607537 5"|"6084938"|"6134096"|"6169652"|"6 185085"|"6215642"|"6351367"|"63613 13"|"6377060"|"6404483"|"6480369"|" 6522519"|"6556414"|"6606234"|"6721 035"|"6839217").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/02/23 10:13
L2	34	($5lithograph$4 or exposure) and ((reticle or mask or article or substrate or wafer or target) near5 (handler or robot or transport$4 or convey$4 or handl$4) near6 (provid$4 or position$4 or plac$4 or integrat$4) near5 (base or support$4 or stage)) and electrostat$6 near4 (clamp$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/02/23 10:35
L3	1	(($5lithograph$4 or exposure) and ((reticle or mask or article or substrate or wafer or target) near5 (handler or robot or transport$4 or convey$4 or handl$4) near6 (provid$4 or position$4 or plac$4 or integrat$4) near5 (base or support$4 or stage)) and electrostat$6 near4 (clamp$5) and (dielectric adj "3" (layer or film))). clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/02/23 10:38
L4	1	(($5lithograph$4 or exposure) and ((reticle or mask or article or substrate or wafer or target) near5 (handler or robot or transport$4 or convey$4 or handl$4) near6 (provid$4 or position$4 or plac$4 or integrat$4) near5 (base or support$4 or stage)) and ((detect$4 or sens$4) near5 (presence or absent or absence) near5 (mask or reticle or substrate or wafer)) and (electrostat$6 near3 clamp$4)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/02/23 10:41